

| L Number | Hits   | Search Text   | DB  | Time stamp          |
|----------|--------|---|---|---------------------|
| 1        | 404987 | (polymer\$3 or plastic\$3 or non\$2conduct\$10 or non\$2metallic) near3 (substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3)   | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | 2003/08/11<br>14:59 |
| 2        | 54614  | ((polymer\$3 or plastic\$3 or non\$2conduct\$10 or non\$2metallic) near3 (substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3)) and ((substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3) near3 (radiat\$10 or irradiat\$10 or expos\$10 or illuminat\$10))  | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | 2003/08/11<br>15:06 |
| 3        | 13605  | ((polymer\$3 or plastic\$3 or non\$2conduct\$10 or non\$2metallic) near3 (substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3)) and ((substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3) near3 (radiat\$10 or irradiat\$10 or expos\$10 or illuminat\$10))) and ((substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3) near10 (laser or UV or ultraviolet))   | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | 2003/08/11<br>15:02 |
| 4        | 2627   | ((polymer\$3 or plastic\$3 or non\$2conduct\$10 or non\$2metallic) near3 (substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3)) and ((substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3) near3 (radiat\$10 or irradiat\$10 or expos\$10 or illuminat\$10))) and ((substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3) near10 (laser or UV or ultraviolet))) and ((laser or UV or ultraviolet) same (discharge or plasma))  | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | 2003/08/11<br>16:49 |
| 5        | 0      | ((polymer\$3 or plastic\$3 or non\$2conduct\$10 or non\$2metallic) near3 (substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3)) and ((substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3) near3 (radiat\$10 or irradiat\$10 or expos\$10 or illuminat\$10))) and ((substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3) near10 (laser or UV or ultraviolet))) and ((laser or UV or ultraviolet) same (discharge or plasma))) and ((discharge or plasma) near15 (electrode\$3 or anode\$3 or cathode\$3)) | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | 2003/08/11<br>16:31 |

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| 6  | 608  | ((((polymer\$3 or plastic\$3 or non\$2conduct\$10 or non\$2metallic) near3 (substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3)) and ((substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3) near3 (radiat\$10 or irradiat\$10 or expos\$10 or illuminat\$10))) and ((substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3) near10 (laser or UV or ultraviolet))) and ((laser or UV or ultraviolet) same (discharge or plasma))) and ((discharge or plasma) near15 (electrode\$3 or anode\$3 or cathode\$3))  | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | 2003/08/11<br>15:04 |
| 7  | 297  | ((((polymer\$3 or plastic\$3 or non\$2conduct\$10 or non\$2metallic) near3 (substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3)) and ((substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3) near3 (radiat\$10 or irradiat\$10 or expos\$10 or illuminat\$10))) and ((substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3) near10 (laser or UV or ultraviolet))) and ((laser or UV or ultraviolet) same (discharge or plasma))) and ((discharge or plasma) near15 (electrode\$3 or anode\$3 or cathode\$3))) and ((jet\$10 or flow\$10 or spray\$10 or inject\$10 or circulat\$10 or input or deliver\$10 or nozzle\$3) near5 gas\$3)  | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | 2003/08/11<br>16:31 |
| 8  | 175  | ((((polymer\$3 or plastic\$3 or non\$2conduct\$10 or non\$2metallic) near3 (substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3)) and ((substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3) near3 (radiat\$10 or irradiat\$10 or expos\$10 or illuminat\$10))) and ((substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3) near10 (laser or UV or ultraviolet))) and ((laser or UV or ultraviolet) same (discharge or plasma))) and ((discharge or plasma) near15 (electrode\$3 or anode\$3 or cathode\$3))) and ((jet\$10 or flow\$10 or spray\$10 or inject\$10 or circulat\$10 or input or deliver\$10 or nozzle\$3) near5 gas\$3)) and ((substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3) near5 (continuous\$3 or mov\$10 or convey\$10 or transport\$10)) | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | 2003/08/11<br>16:25 |
| 9  | 1530 | ((polymer\$3 or plastic\$3 or non\$2conduct\$10 or non\$2metallic) near3 (substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3)) and ((cloud or plume or zone) near10 (plasma or discharge))  | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | 2003/08/11<br>16:30 |
| 10 | 573  | ((polymer\$3 or plastic\$3 or non\$2conduct\$10 or non\$2metallic) near3 (substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3)) and ((cloud or plume or zone) near10 (plasma or discharge))) and ((discharge or plasma) near15 (electrode\$3 or anode\$3 or cathode\$3))   | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | 2003/08/11<br>16:31 |

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|----|------|---|---|---------------------|
| 11 | 354  | (((((polymer\$3 or plastic\$3 or non\$2conduct\$10 or non\$2metallic) near3 (substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3)) and ((cloud or plume or zone) near10 (plasma or discharge))) and ((discharge or plasma) near15 (electrode\$3 or anode\$3 or cathode\$3))) and ((jet\$10 or flow\$10 or spray\$10 or inject\$10 or circulat\$10 or input or deliver\$10 or nozzle\$3) near5 gas\$3))  | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | 2003/08/11<br>16:32 |
| 12 | 128  | (((((polymer\$3 or plastic\$3 or non\$2conduct\$10 or non\$2metallic) near3 (substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3)) and ((cloud or plume or zone) near10 (plasma or discharge))) and ((discharge or plasma) near15 (electrode\$3 or anode\$3 or cathode\$3))) and ((jet\$10 or flow\$10 or spray\$10 or inject\$10 or circulat\$10 or input or deliver\$10 or nozzle\$3) near5 gas\$3)) and (laser or UV or ultraviolet)   | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | 2003/08/11<br>16:49 |
| 13 | 6705 | ((laser or UV or ultraviolet) same (discharge or plasma) same (cloud or plume or zone or site or location or area))   | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | 2003/08/11<br>16:51 |
| 14 | 170  | ((laser or UV or ultraviolet) same (discharge or plasma) same (cloud or plume or zone or site or location or area)) and (reactive adj gas)  | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | 2003/08/11<br>16:51 |
| 15 | 164  | ((laser or UV or ultraviolet) same (discharge or plasma) same (cloud or plume or zone or site or location or area)) and (reactive adj gas)) not ((((((polymer\$3 or plastic\$3 or non\$2conduct\$10 or non\$2metallic) near3 (substrate\$3 or article\$3 or part\$3 or workpiece\$3 or component\$3 or surface\$3)) and ((cloud or plume or zone) near10 (plasma or discharge))) and ((discharge or plasma) near15 (electrode\$3 or anode\$3 or cathode\$3))) and ((jet\$10 or flow\$10 or spray\$10 or inject\$10 or circulat\$10 or input or deliver\$10 or nozzle\$3) near5 gas\$3)) and (laser or UV or ultraviolet)) | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | 2003/08/11<br>16:52 |